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Document(s) Attached: Supplemental Amendment Total Pages (incl. this Sheet): 4

In re application of:	Joel DeSouza et al.
Scrial Number:	10/604,146
	Conf. No. 1145
Filing Date:	June 27, 2003
	H. Daniel Schnurmann IBM Corporation Dept.18G, B/321, Zip 482 2070 Route 52 Hopewell Junction, NY 12533

PLEASE DELIVER TO:		
EXAMINER ART UNIT: FAX NO:	Jack. S. J. Chen 2813 571-273-8300	
FROM:	Daryl K. Neff 4 Eugene Circle Lincoln Park, NJ 07035 Phone 973-316-2612	

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Dated July 19, 2008 Signature Qaryl K. Neff)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE		
In re application of: Joel P. DeSouza et al.	Date: July 19, 2008	
Serial Number: 10/604,146	Examiner: Jack S. J. Chen	
Filed: June 27, 2003	Group Art Unit: 2813 Conf. No. 1145	
Title: SIMOX METHOD OF MAKING A BURIED OXIDE LAYER USING BASE IMPLANT AND ROOM TEMPERATURE IMPLANT	H. Daniel Schnurmann IBM Corporation Dept. 18G, B/321, Zip 482 2070 Route 52 Hopewell Junction, NY 12533	

SUPPLEMENTAL AMENDMENT

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Supplemental to the amendment filed July 18, 2008, Applicants submit the following additional remarks for the Examiner's consideration.